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(12) **United States Design Patent**  
**Dehaan et al.**

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(54) **FACE MASK**

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(\*\*) **Term:** **14 Years**

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(51) **LOC (7) Cl.** ..... **29-02**

(52) **U.S. Cl.** ..... **D29/108; D29/122**

(58) **Field of Search** ..... D29/102-111,  
D29/122; 2/410, 6.3, 6.6, 6.7, 6.8, 411,  
414, 415, 423, 424, 425, 457, 468, 206,  
9, 15; 128/857-861

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(57) **CLAIM**

The ornamental design for a face mask, as shown and described.

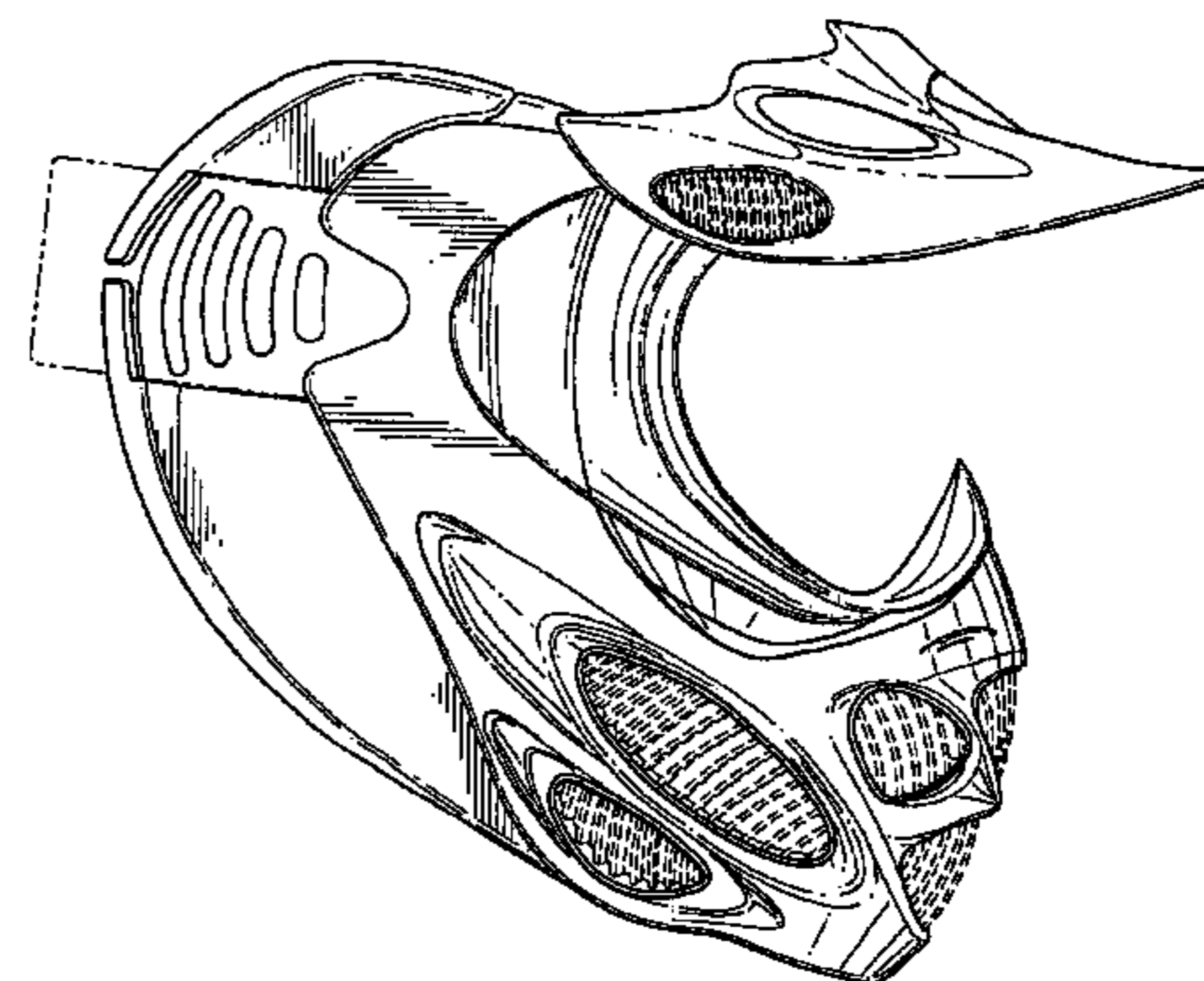
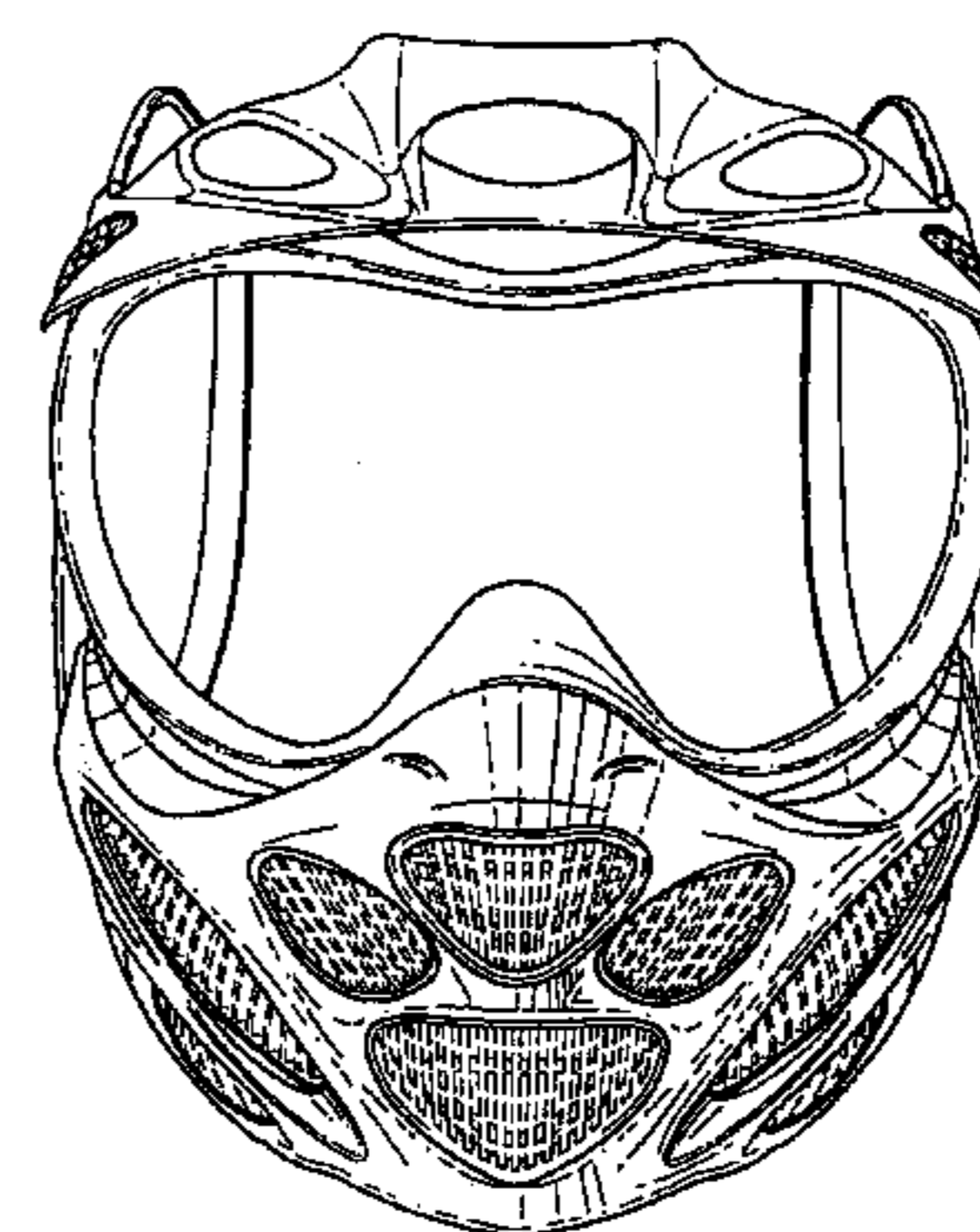
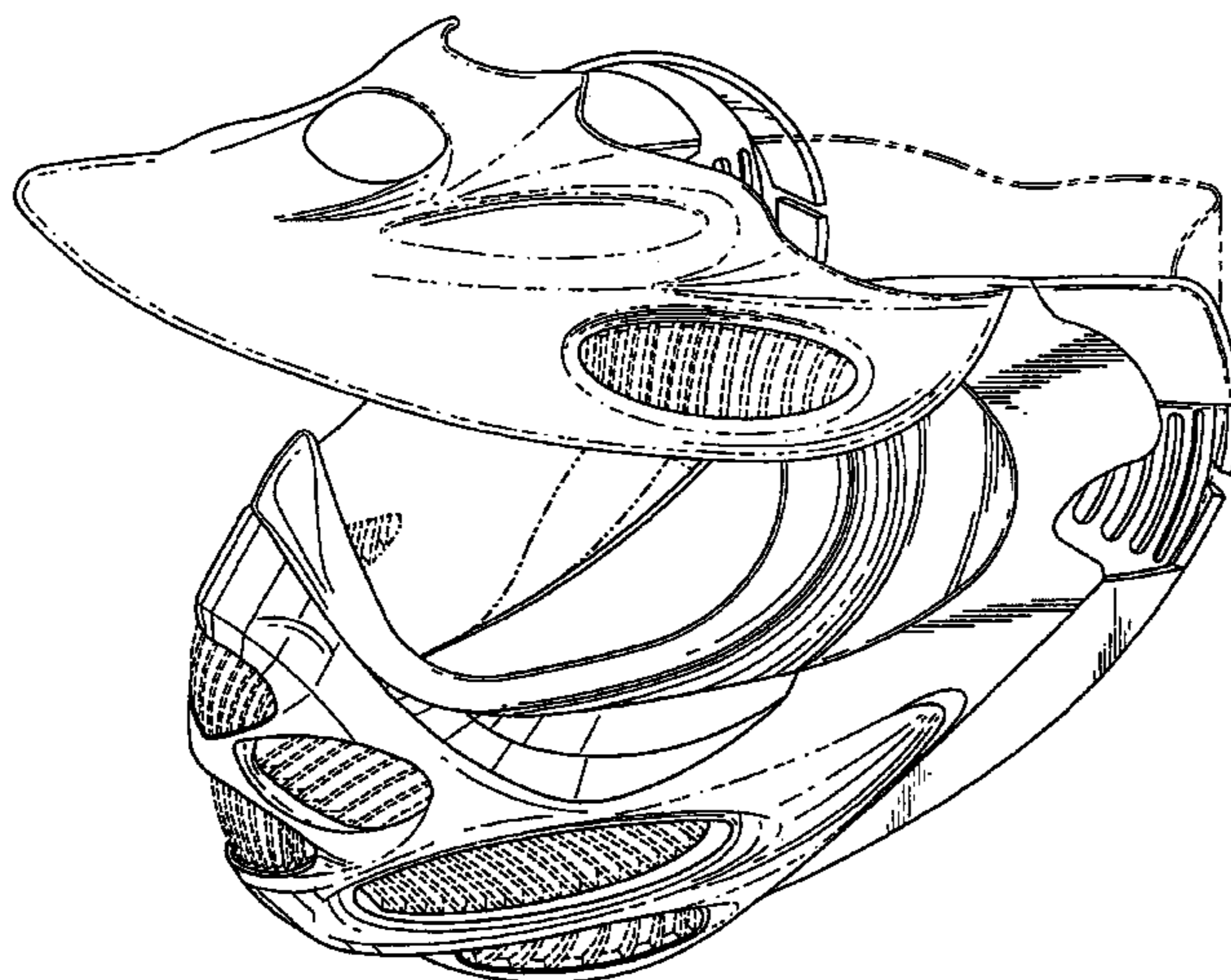
**DESCRIPTION**

FIG. 1 is a right, front and top perspective view of a face mask showing our new design;

FIG. 2 is a front elevation view thereof; and,

FIG. 3 is a left side elevation view thereof.

**1 Claim, 2 Drawing Sheets**



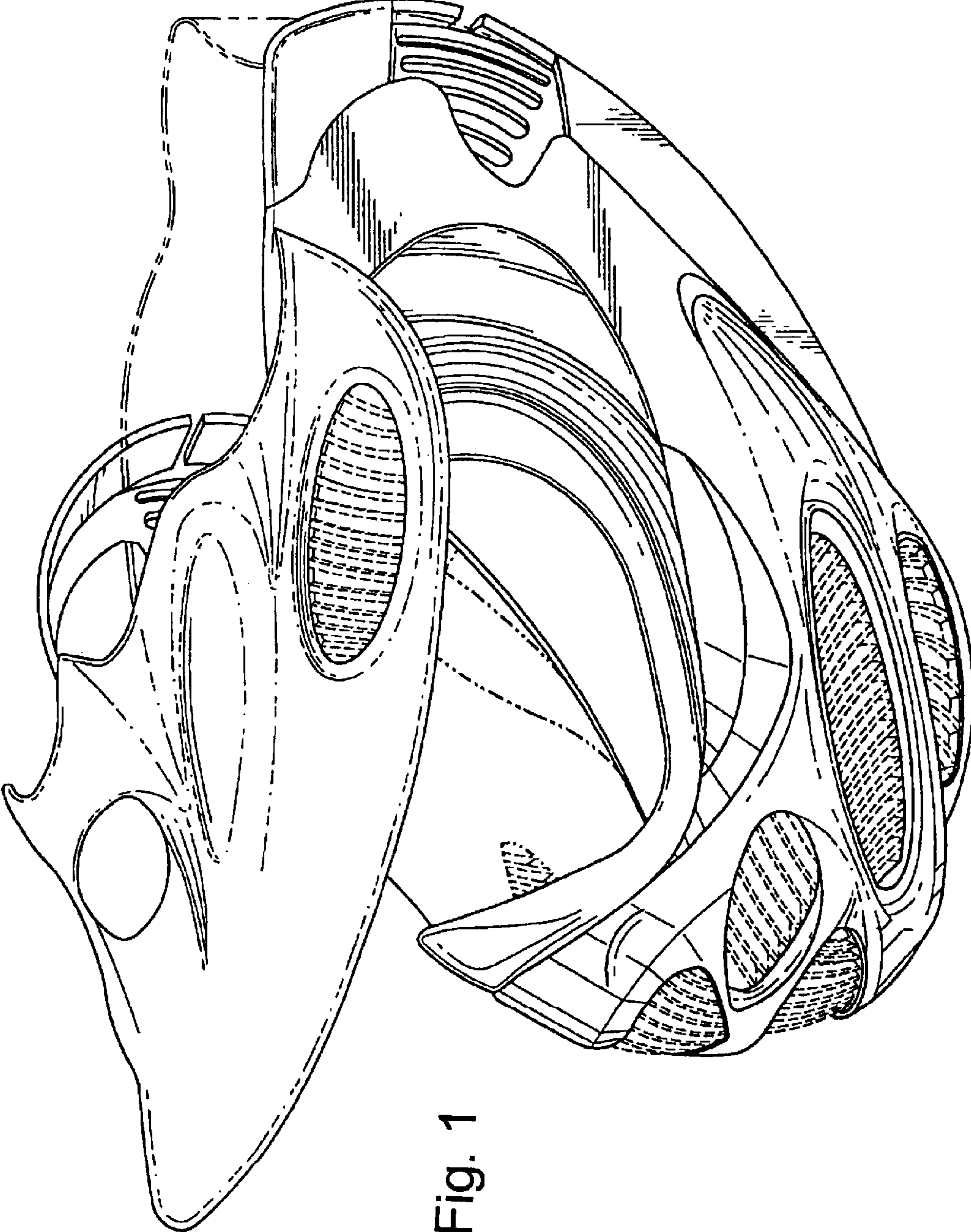


Fig. 1



Fig. 2

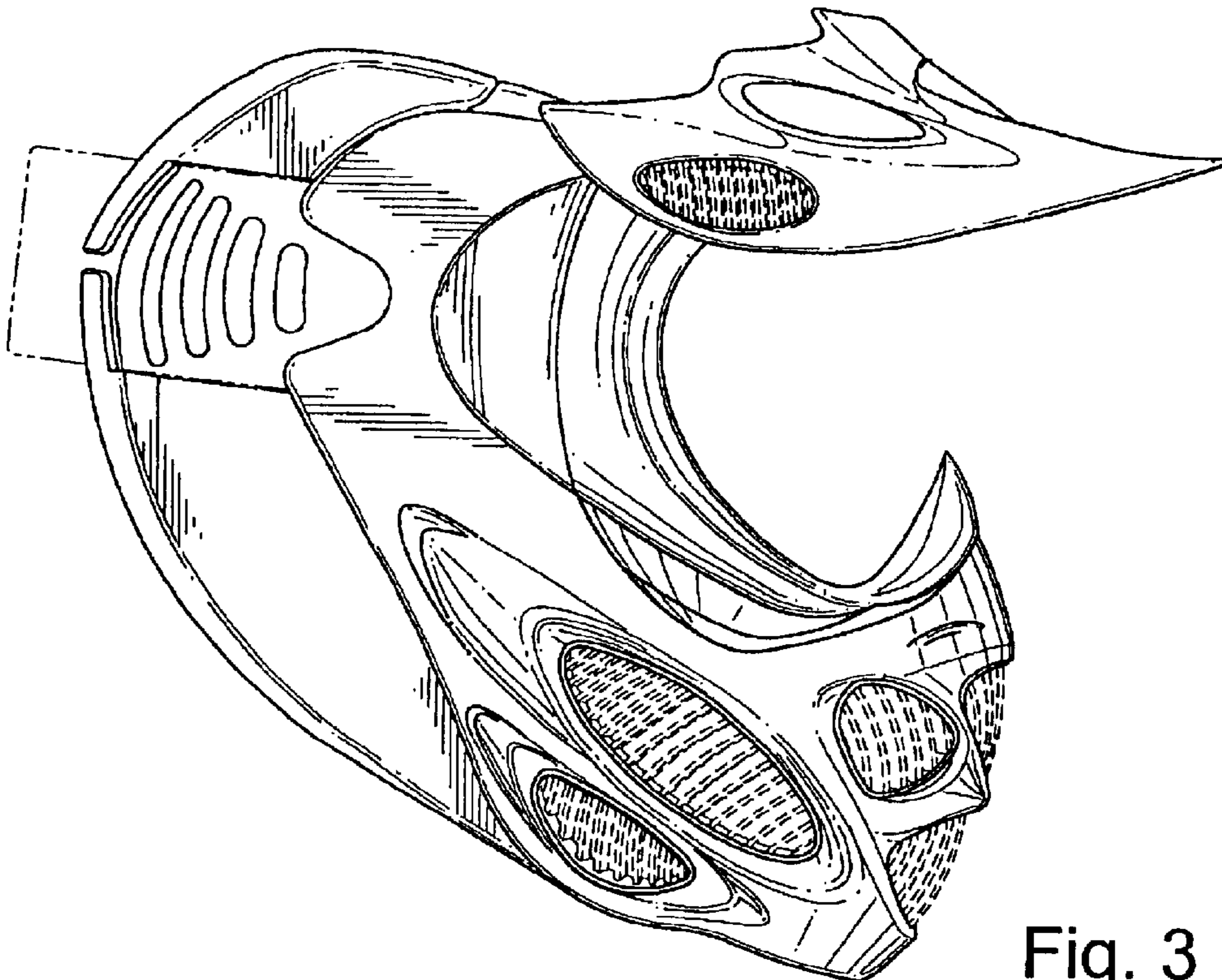
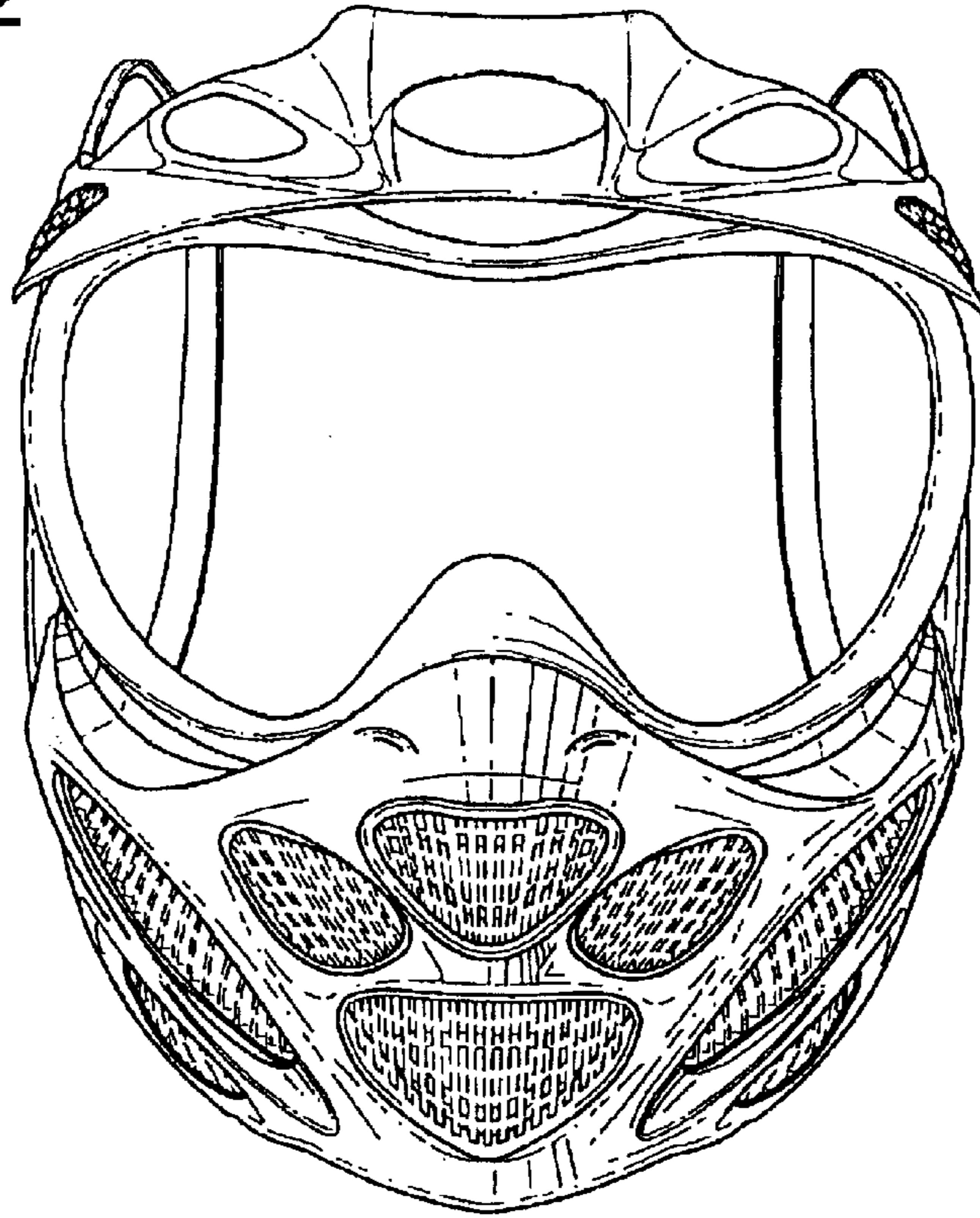


Fig. 3